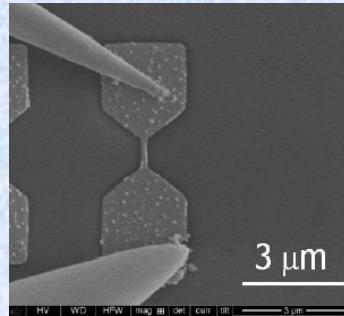
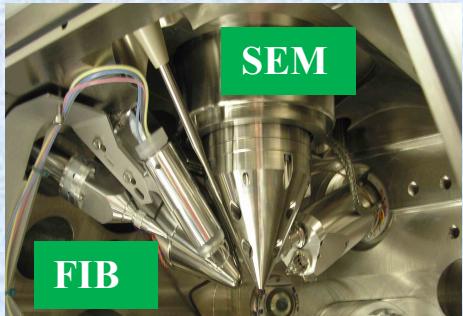


Research lines and facilities on Nanolithography in Zaragoza

LABORATORIO DE MICROSCOPIAS AVANZADAS (LMA) ICTS-ELECFMI



José María De Teresa

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NANOMIDAS GROUP

Nanofabrication and Advanced Microscopies
CSIC-University of Zaragoza (Spain)

Nanofabrication team

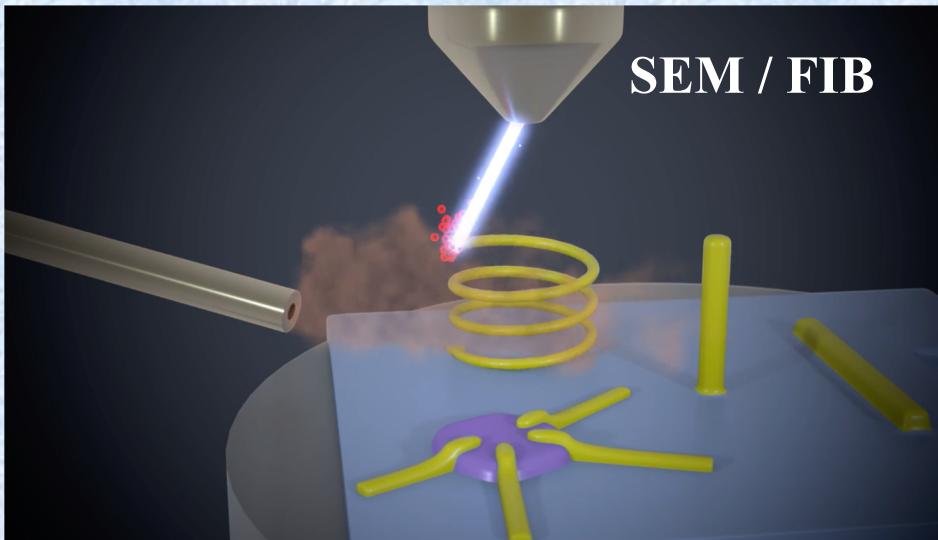


<https://nanofab-deteresa.com>

OVERVIEW OF CURRENT RESEARCH LINES

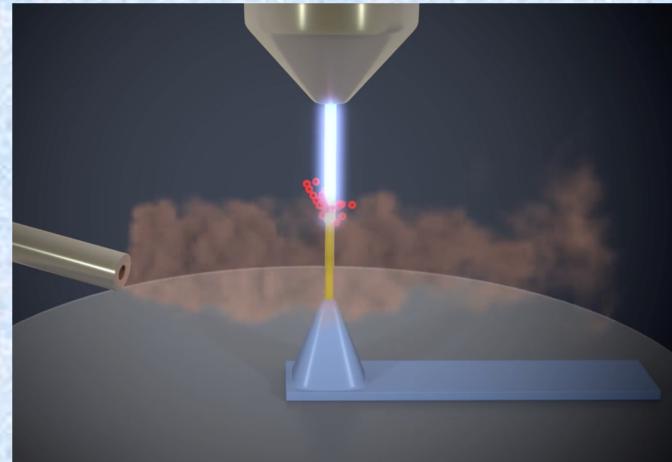
1. Metallic nanostructures by Focused Ion Beam Induced Deposition (FIBID) and Cryo-FIBID
2. Magnetic nanostructures by Focused Electron Beam Induced Deposition (FEBID) and FIBID
3. Superconducting nanostructures and devices by FIBID

FOCUSED ELECTRON/ION BEAM INDUCED DEPOSITION (FEBID/FIBID)



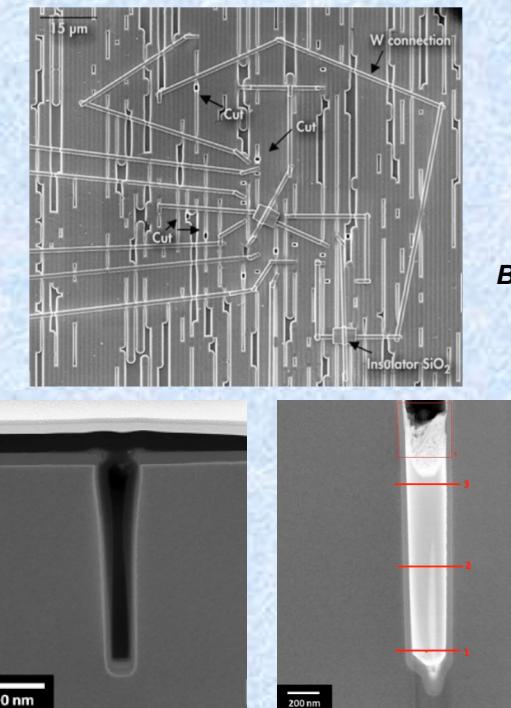
COMPETITIVE ADVANTAGES:

- ONE-STEP LITHOGRAPHY
- ON ANY SUBSTRATE
- 3D GROWTH
- HIGH RESOLUTION

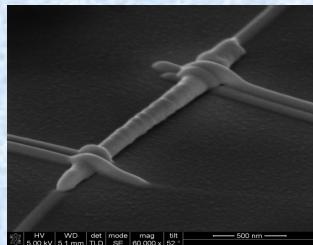


SOME APPLICATIONS OF FEBID/FIBID

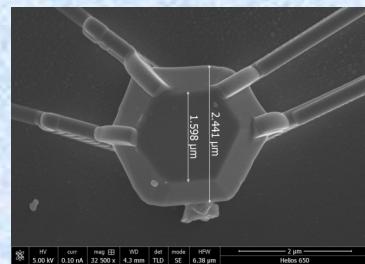
Electrical contacts during circuit editing



Electrical contacts to nano-objects

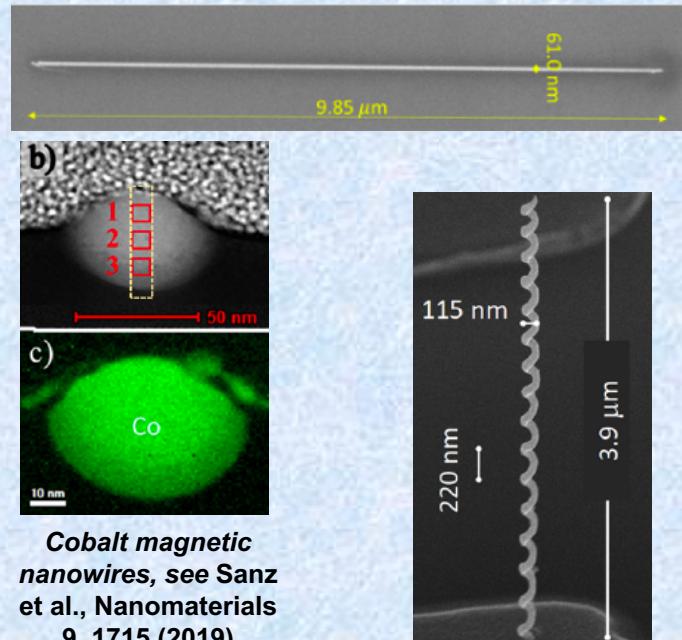


Bismuth single-crystal nanowires, see Marcano et al., Appl. Phys. Lett. 96, 082110 (2010)



SrRu_2O_6 microcrystals, see Hiley et al., Phys. Rev. B 92, 104413 (2015)

Growth of superconducting or magnetic materials



Cobalt magnetic nanowires, see Sanz et al., Nanomaterials 9, 1715 (2019)

W-C superconducting nanowires, see Córdoba et al., Nano Letters 19, 8597 (2019)

1. **Metallic** nanostructures by Focused Ion Beam Induced Deposition (FIBID) and Cryo-FIBID
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3. **Superconducting** nanostructures and devices by FIBID

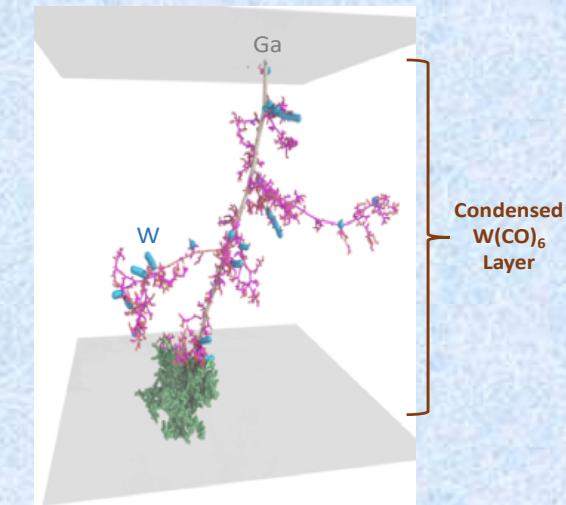
FIBID under cryogenic conditions (Cryo-FIBID)

J. M. De Teresa et al., patent submitted (WO2020021149); R. Córdoba et al., *Scientific Reports* 9, 14076 (2019)

J. M. De Teresa et al., *Micromachines* 10, 799 (2019); A. Salvador et al., *Nanomaterials* 10, 1906 (2020)

A. Salvador et al., manuscript in preparation

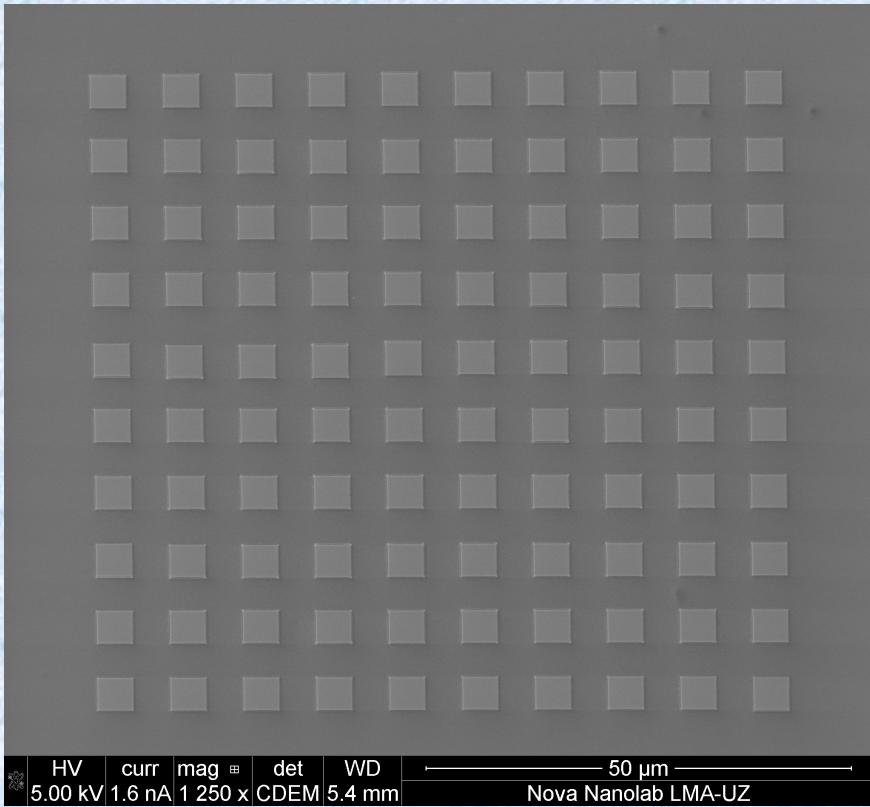
Focused Ion Beam Induced Deposition (FIBID) in cryogenic conditions (Cryo-FIBID)



SDTRIMSP simulations by
P. Philipp (U. Luxembourg)

Ga⁺-FIBID under cryogenic conditions (Cryo-FIBID)

*W(CO)₆
precursor*



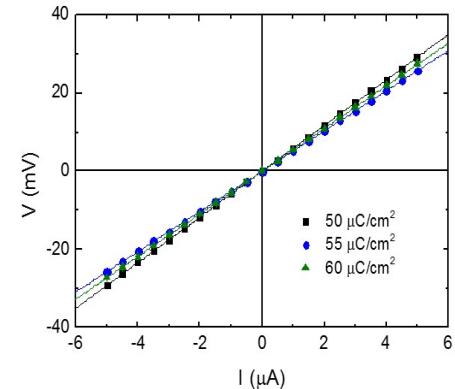
*ARRAY of 100 SQUARES OF
W-C DEPOSITS*

- TOTAL AREA= 100 x 25 μm^2
- TOTAL ION IRRADIATION TIME= **85 SECONDS**
- ION IRRADIATION TIME USING FIBID AT ROOM TEMPERATURE= **14 HOURS**

*THE PROCESS IS 600 TIMES
FASTER BY CRYO-FIBID !*

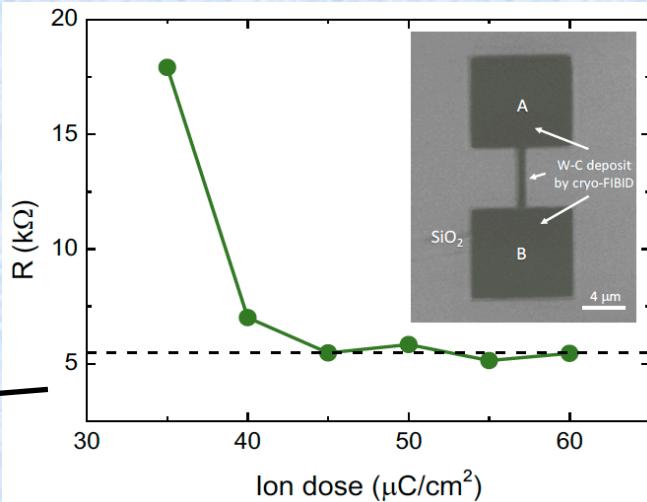
Ga^+ -FIBID under cryogenic conditions (Cryo-FIBID)

Transport experiments at room temperature

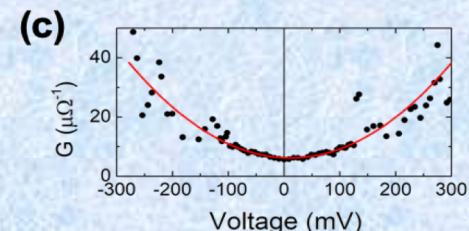
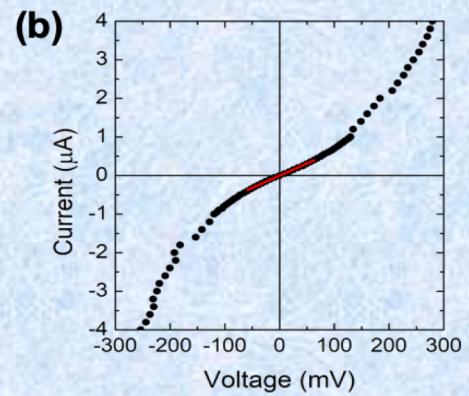
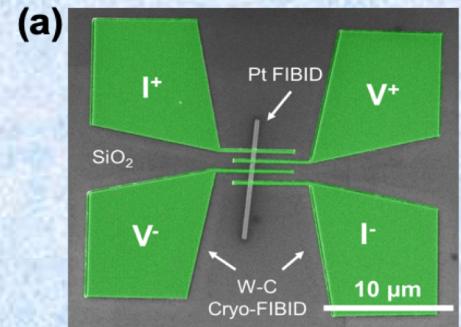


$W(\text{CO})_6$
precursor

Linear I vs V : Metallic behaviour

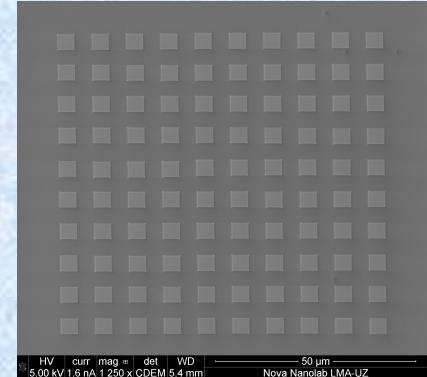
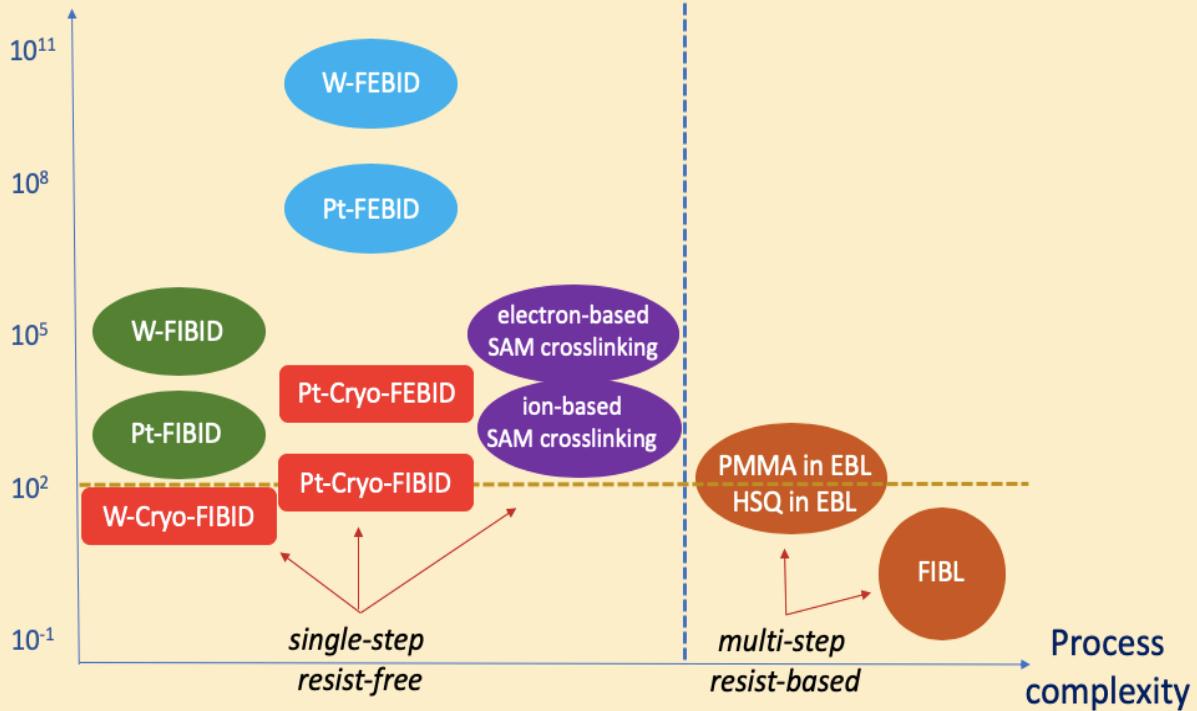


Resistivity
of $800 \mu\Omega\text{cm}$

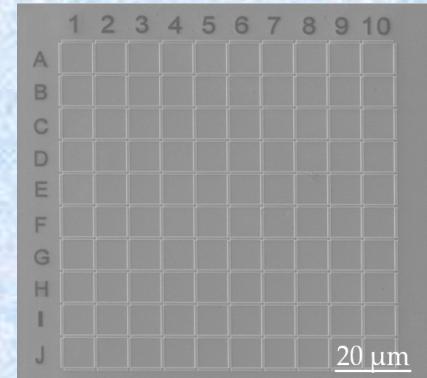


Comparison of RT FIBID and Cryo-FIBID

Area dose ($\mu\text{C}/\text{cm}^2$)



(W-C deposits by Cryo-FIBID,
85 s irradiation, instead of 14 h)

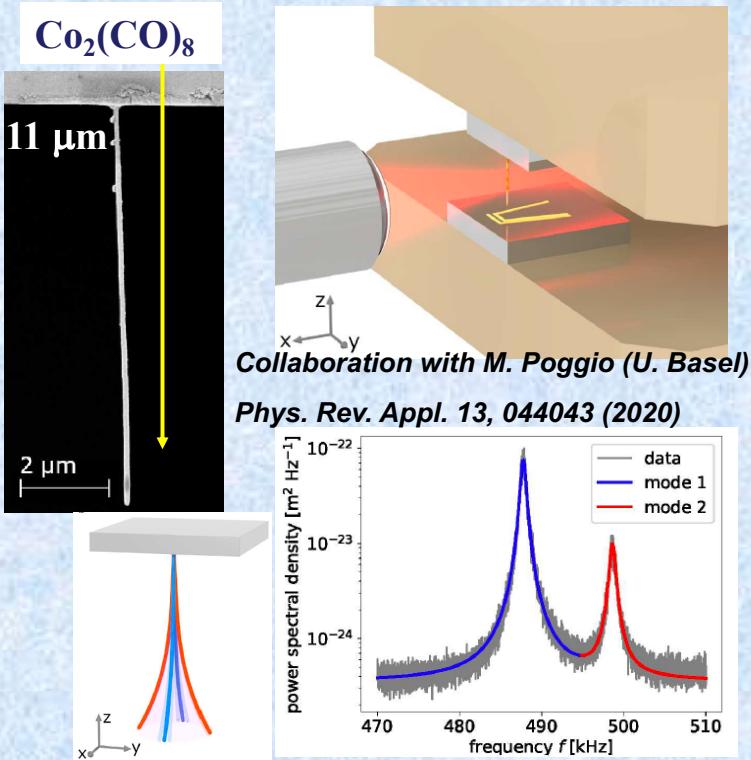


(Pt-C deposits by Cryo-FIBID,
43 s irradiation instead of 2.5 h)

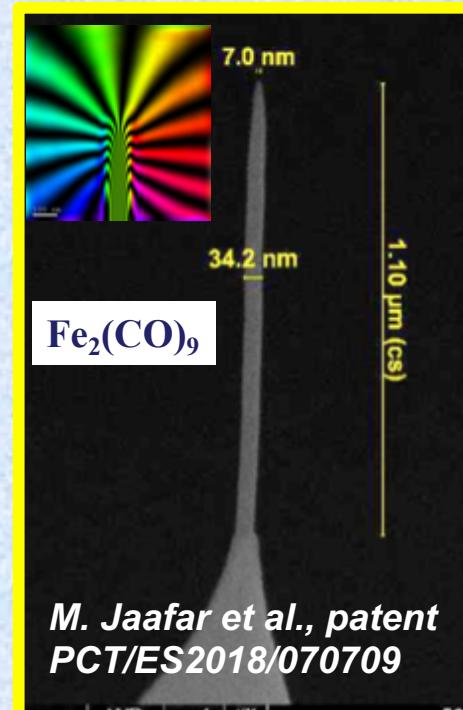
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Fe and Co magnetic nanowires for MFM tips

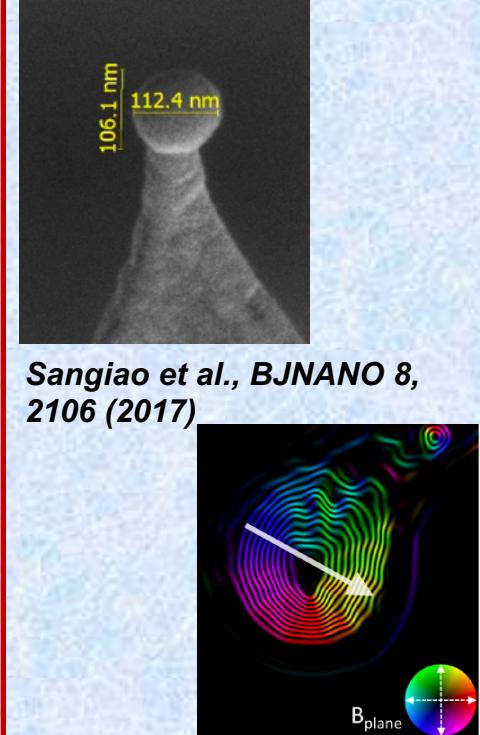
Very long Co tips can be grown for highly-sensitive magnetic force sensors



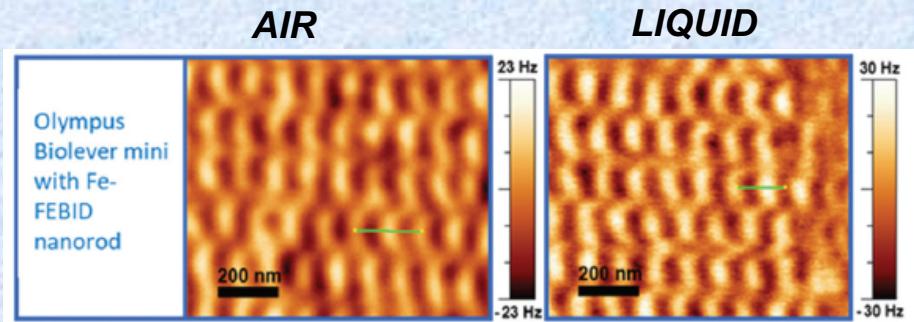
Very sharp tips can be grown for high-resolution MFM measurements



Magnetic nanospheres for FMRFM

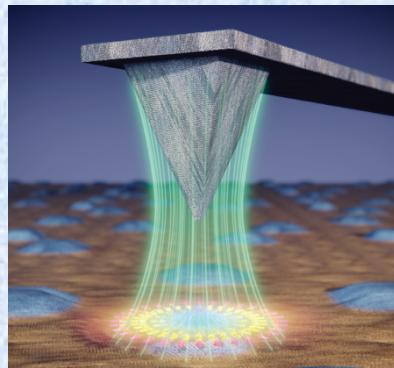


MFM tips for use under liquid environment

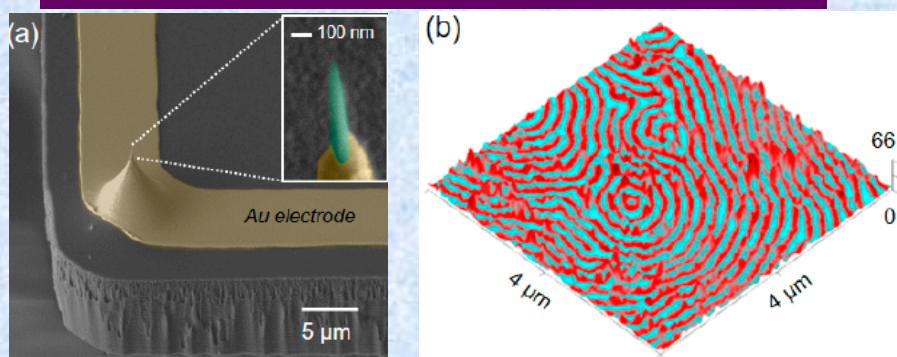


M. Jaafar et al., Nanoscale 12, 10090 (2020)

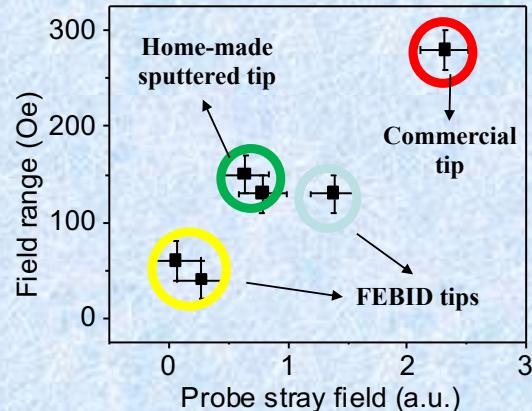
MFM tips for use on soft magnetic structures



MFM tips for AFSEM



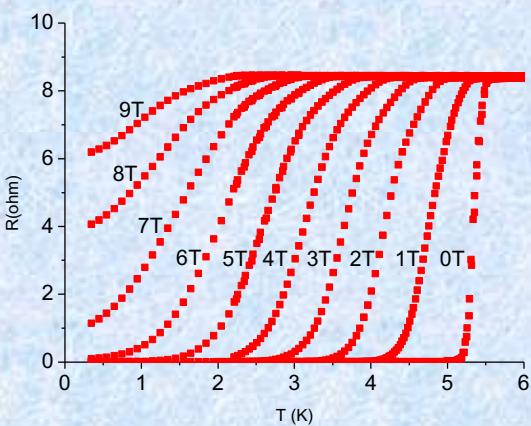
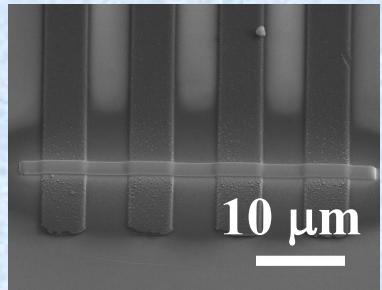
H. Plank et al., Micromachines 11, 48 (2020)



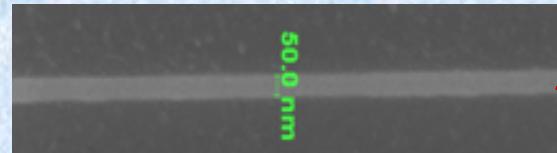
E. Berganza et al., Nanoscale 12, 18646 (2020)

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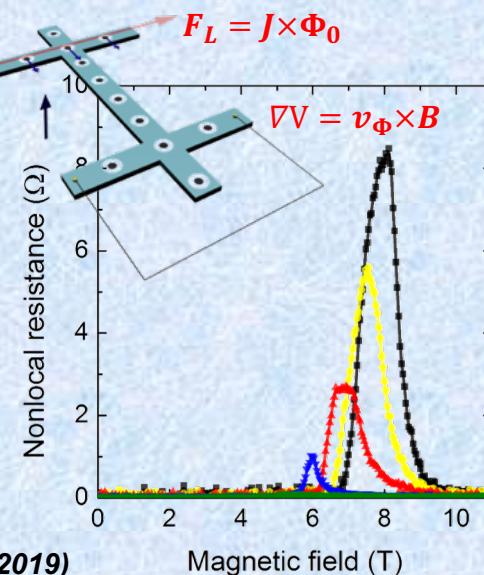
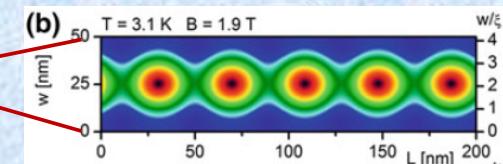
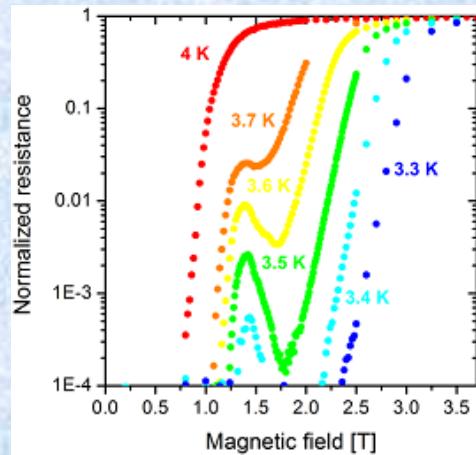
W-C superconducting nanostructures and devices by Ga⁺-FIBID



De Teresa et al., MRS proceedings
1180, 1180-CC04-09 (2009)



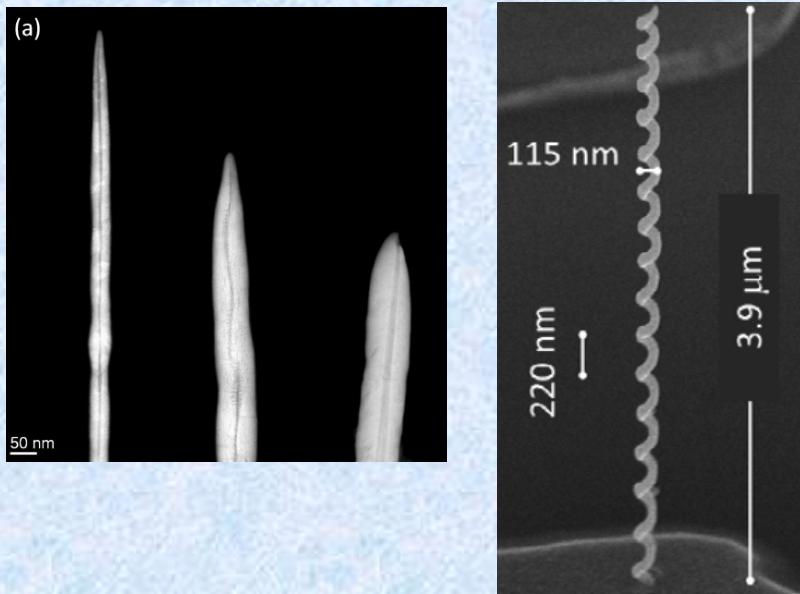
R. Córdoba et al., Nature Commun. 4 (2013) 1437



R. Córdoba et al., Sci. Rpts. 9, 12386 (2019)

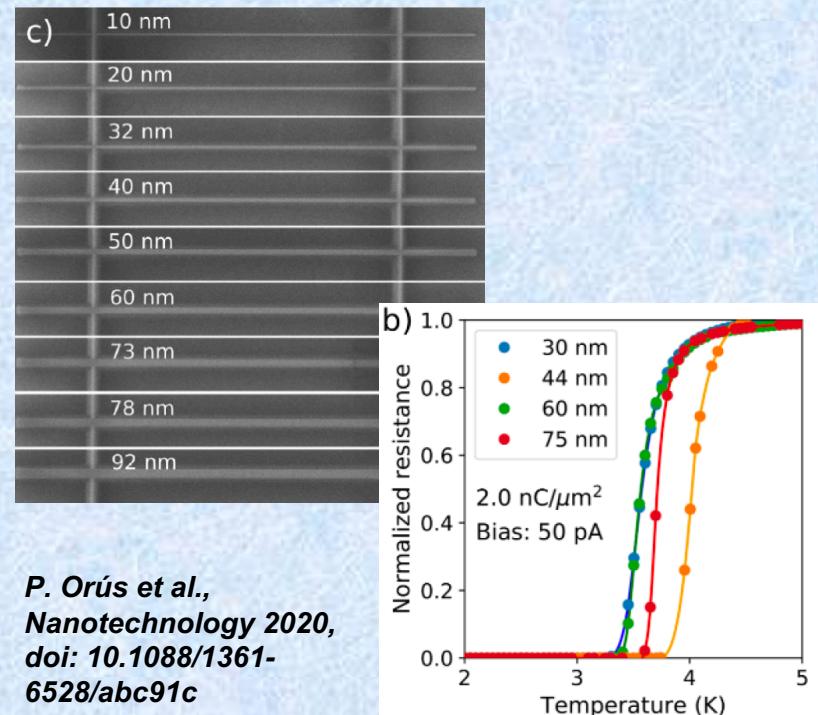
W-C superconducting nanostructures and devices by He⁺-FIBID

out-of-plane linear nanowires (grown at HIM in Paris)



R. Córdoba et al., *Nano Letters* 18, 1379 (2018); *Nano Letters* 19, 8597 (2019); *BJNANO* 11, 1198 (2020)

in-plane nanowires (grown at HIM in Dresden)



P. Orús et al.,
Nanotechnology 2020,
doi: 10.1088/1361-
6528/abc91c

FET-OPEN Project kick-off meeting

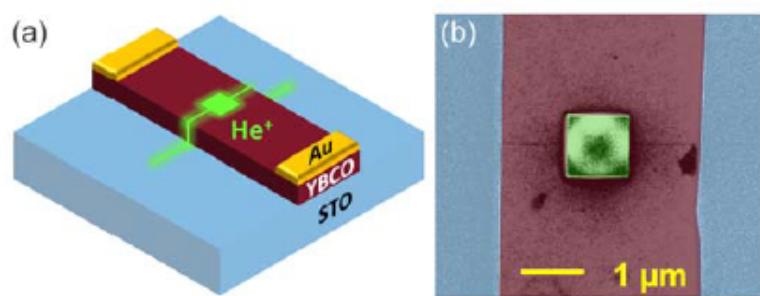
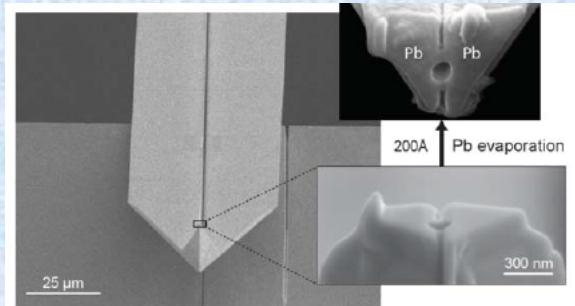
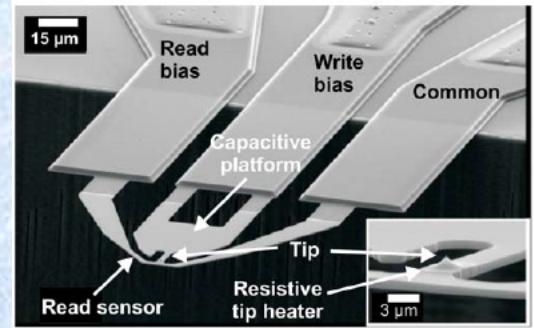
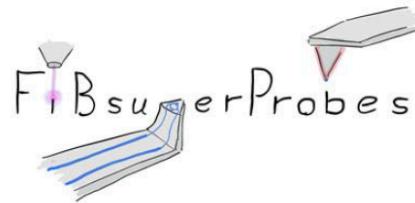
<https://www.fibsuperprobes.com/>



J. M. De Teresa (IP), C. Magén,
S. Sangiao, P. Orús

Focused Ion Beam fabrication of superconducting scanning Probes

FIBsuperProbes



Nanofabrication

Nanolithography techniques and their applications

José María De Teresa Nogueras



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Secondly, I want to express my gratitude to the colleagues from the Spanish network on Nanolithography (NANOLITO) for sharing their knowledge on the topic for the last 12 years in the course of summer schools and workshops.

